



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#  
17/W.M.  
2/28/01

In re application of :  
Hiroshi TAKANASHI et al : Docket No. 01497/FP/TOK-16-US/YH  
Serial No. 09/262,077 : Group Art Unit 1752  
Filed March 4, 1999 : Examiner S. Lee

NEGATIVE-WORKING PHOTOSENSITIVE : THE COMMISSIONER IS AUTHORIZED  
RESIN COMPOSITION AND PHOTO- : TO CHARGE ANY DEFICIENCY IN THE  
SENSITIVE RESIN PLATE USING THE : FEES FOR THIS PAPER TO DEPOSIT  
SAME : ACCOUNT NO. 23-0975

NOTICE OF APPEAL

Assistant Commissioner for Patents  
Washington, DC 20231

Sir:

Applicant hereby appeals to the Board of Appeals from the decision dated September 20, 2000 of the Primary Examiner finally rejecting claims 6 to 9.


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- (X) A timely response to the final rejection has been filed.
- (X) The extension fee of \$390.00 for a two month extension of time is submitted with the attached Petition for Extension of Time.
- (X) The Appeal Fee of [X] \$310.00 (other than Small Entity)  
[ ] \$155.00 (Small Entity)
- (X) is enclosed  
( ) is to be charged to Deposit Account No. 23-0975. The original and two copies of this sheet are enclosed.

- ( ) Small entity status of this application is established by the verified statement under 37 CFR 1.9 and 1.27 which
- ( ) is enclosed.
- ( ) has been previously submitted.
- ( ) The Appeal Fee is not required since it was paid in a prior appeal.

Respectfully submitted,

Hiroshi TAKANASHI et al.

By   
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Attorney for Applicants

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February 20, 2001